FASH 62A Course Outline as of Fall 2020

CATALOG INFORMATION

Dept and Nbr: FASH 62A Title: FLAT PATTERN DESIGN 1

Full Title: Flat Pattern Design 1 Last Reviewed: 2/24/2020

| Units | | Course Hours per Week | (| Nbr of Weeks | Course Hours Total | |
|---------|------|-----------------------|----------|--------------|---------------------------|-------|
| Maximum | 2.00 | Lecture Scheduled | 1.50 | 17.5 | Lecture Scheduled | 26.25 |
| Minimum | 2.00 | Lab Scheduled | 2.50 | 6 | Lab Scheduled | 43.75 |
| | | Contact DHR | 0 | | Contact DHR | 0 |
| | | Contact Total | 4.00 | | Contact Total | 70.00 |
| | | Non-contact DHR | 0 | | Non-contact DHR | 0 |

Total Out of Class Hours: 52.50 Total Student Learning Hours: 122.50

Title 5 Category: AA Degree Applicable

Grading: Grade or P/NP

Repeatability: 00 - Two Repeats if Grade was D, F, NC, or NP

Also Listed As:

Formerly: CLTX 50A

Catalog Description:

The student will learn the flat pattern method in which a sloper is used to create patterns for a variety of garment styles. Patterns for tops, skirts, dresses, sleeves, and collars are discussed. Construction of a garment from an original pattern is required.

Prerequisites/Corequisites:

Course Completion of FASH 70A

Recommended Preparation:

Course Completion of FASH 70B; AND Course Completion or Concurrent Enrollment in FASH 56

Limits on Enrollment:

Schedule of Classes Information:

Description: The student will learn the flat pattern method in which a sloper is used to create patterns for a variety of garment styles. Patterns for tops, skirts, dresses, sleeves, and collars are discussed. Construction of a garment from an original pattern is required. (Grade or P/NP)

Prerequisites/Corequisites: Course Completion of FASH 70A

Recommended: Course Completion of FASH 70B; AND Course Completion or Concurrent

Enrollment in FASH 56 Limits on Enrollment: Transfer Credit: CSU:

Repeatability: Two Repeats if Grade was D, F, NC, or NP

ARTICULATION, MAJOR, and CERTIFICATION INFORMATION:

AS Degree: Area Effective: Inactive: CSU GE: Transfer Area Effective: Inactive:

IGETC: Transfer Area Effective: Inactive:

CSU Transfer: Transferable Effective: Fall 1987 Inactive:

UC Transfer: Effective: Inactive:

CID:

Certificate/Major Applicable:

Both Certificate and Major Applicable

COURSE CONTENT

Student Learning Outcomes:

At the conclusion of this course, the student should be able to:

- 1. Demonstrate basic principles of flat patternmaking.
- 2. Explain the stages of apparel production.

Objectives:

At the conclusion of this course, the student should be able to:

- 1. Interpret flat sketches of garment designs to determine the required pattern pieces for the style.
- 2. Compare body measurements, pattern piece dimensions, fitting ease, and style ease in order to achieve proper fit.
- 3. Create several slopers in tag paper to use for developing patterns for a variety of garment styles.
- 4. Manipulate the basic sloper using flat pattern method to create patterns for garments and their various parts including, but not limited to: tops, skirts, dresses, sleeves, collars, facings, and button plackets.
- 5. Produce a production-ready garment pattern, with accurate labeling and markings, which can be used in the apparel industry.
- 6. Study the stages of garment production in the fashion industry from the design development to the sales floor.
- 7. Identify the different roles that patternmakers can have within the apparel industry.

Topics and Scope:

- I. Analysis of the Garment Design
 - A. Definition and Interpretation of a Flat Sketch
 - B. Understanding fit; style ease and fitting ease

- II. Methods of Flat Patternmaking
 - A. Slash Method
 - B. Pivot/transfer method
- III. Basic Flat Pattern Techniques
 - A. Dart manipulation
 - B. Adding Fullness
 - C. Contouring
- IV. Using a Sloper to Create Basic Designs
 - A. Tops and bodices
 - B. Skirts
 - C. Dresses
 - D. Sleeves
 - E. Collars
 - F. Facings and linings
 - G. Closures
- V. Application of Flat Patternmaking Within the Apparel Industry
 - A. Overview of apparel industry
 - B. Jobs and responsibilities of patternmaker
 - C. Different markets of the apparel industry
 - D. Industrial Flat pattern computer technologies

All topics are covered in both the lecture and lab parts of the course.

Assignment:

Lecture-Related Assignments:

- 1. Read from text (5 15 pages per week)
- 2. Quizzes on patternmaking techniques and theories (2 3)

Lab-Related Assignments:

- 1. Complete half scale design exercises and compile in a reference binder (10-12)
- 2. Complete full scale 5-piece basic pattern sloper on tag paper
- 3. Pattern and sew full scale garment samples to test pattern manipulations (2-3)
- 4. Final Project: Design, pattern, and sew an original garment design with a production ready paper pattern

Methods of Evaluation/Basis of Grade:

Writing: Assessment tools that demonstrate writing skills and/or require students to select, organize and explain ideas in writing.

None, This is a degree applicable course but assessment tools based on writing are not included because problem solving assessments and skill demonstrations are more appropriate for this course.

Writing 0 - 0%

Problem Solving: Assessment tools, other than exams, that demonstrate competence in computational or non-computational problem solving skills.

Final Project (Pattern and construction of garment)

Problem solving 10 - 20%

Skill Demonstrations: All skill-based and physical demonstrations used for assessment purposes including skill performance exams.

Pattern Design and Sewing Exercises, Basic Sloper, Final Project

Skill Demonstrations 50 - 70%

Exams: All forms of formal testing, other than skill performance exams.

Quizzes

Exams 10 - 15%

Other: Includes any assessment tools that do not logically fit into the above categories.

Attendance and participation

Other Category 10 - 20%

Representative Textbooks and Materials:

Pattern Design Fundamentals. Matthews-Fairbanks, Jennifer Lynne. Fairbanks Publishing. 2018 Principles of Flat Pattern Design. 4th ed. McDonald, Nora. Bloomsbury. 2009 (classic)